FCC ID:2AD66-CC68-915

Maximum Permissible Exposure (MPE)

According to FCC 1.1310: The criteria listed in the following table shall be used to evaluate the environment impact of human exposure to radio frequency(RF) Radiation as specified in §1.1307(b)

Limits for Maximum Permissible Exposure (MPE)

Frequency range (MHz)	Electric field strength (V/m)	Magnetic field strength (A/m)	Power density (mW/cm ²)	Averaging time (minutes)	
	(A) Limits for 0	ccupational/Controlled Exp	osure		
0.3-3.0	614	1.63	*100	6	
3.0-30	1842/	f 4.89/f	*900/f ²	6	
30-300	61.4	0.163	1.0	6	
300-1,500			f/300	6	
1,500-100,000			5	6	
	(B) Limits for Gene	ral Population/Uncontrolled	Exposure		
0.3-1.34	614	1.63	*100	30	
1.34-30	824/	2.19/1	*180/f ²	30	
30-300	27.5	0.073	0.2	30	
300-1,500			f/1500	30	
1,500-100,000			1.0	30	

f = frequency in MHz * = Plane-wave equivalent power density

MPE Calculation Method

$$E (V/m) = \frac{\sqrt{30*P*G}}{d}$$
 Power Density: $Pd (W/m^2) = \frac{E^2}{377}$

E = Electric field (V/m)

P = Average RF output power (W)

G = EUT Antenna numeric gain (numeric)

d = Separation distance between radiator and human body (m)

The formula can be changed to

$$Pd = \frac{30 * P * G}{377 * D^2}$$

From the EUT RF output power, the minimum mobile separation distance, d=0.2m, as well as the gain of the used antenna, the RF power density can be obtained.

Measurement Result

LoRa

Operation Frequency: 903MHz~927.5MHz

Power density limited: 1mW/ cm²

Antenna Type: Spring antenna/Wire antenna

Lora antenna gain: 2dBi;

R=20cm

 $mW=10^{(dBm/10)}$

antenna gain Numeric=10^(dBi/10)= 10^(2/10)=1.58

Channel Freq. r (MHz)	modulation	conducted power	Tune-up power	Max		Antenna	Evaluation result at 20cm	Power density Limits
		(dBm)	(dBm)	tune-up power		Gain	Power	
				(dBm)	(mW)	Numeric	density(mW/cm2	(mW/cm2)
902.8		9.478	9±1	10	10	1.58	0.00314	0.45
914.8	LoRa	9.486	9±1	10	10	1.58	0.00314	0.46
927.3		9.473	9±1	10	10	1.58	0.00314	0.46

Conclusion:

For the max result : 0.00314≤ 0.45 for Max Power Density, Compliance the RF Exposure requirement.

Alex

Signature:

Date: 2021-08-17

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